

250 252 Size 200 . 150 **B**

Al-5wt%Cu Sample Annealing Series

Sample Description

- Al-5wt% Cu
- Crystal system: face-centered cubic (Fm3m)
- Dimension: 1.4 mm (diameter) × 6.5 mm (length)
- Annealing treatment: 15 min @ 630°C, air cooling to RT
- Annealing steps: 10

Sample Courtesy: Dr. Jules Dake, Ulm University, Germany



Figure: Grain size distribution and 3D grain map colored by grain size, initial sample state (tO).



Figure: Grain size distribution and 3D grain map colored by grain size, after 10th annealing step (t10).

References

- J.M. Dake et al., (2016). PNAS, 113, E5998. 1)
- Dr. -Ing. Thesis, Jules Dake, Ulm Univ. 2019. 21
- 3) J. Sun et al., (2024). Tomography of Materials and Structures, 4, 100025.

Open access datasets: https://doi.org/10.18126/5Q8S-3EF9



Figure: Evolution of three neighboring grains after 15min, 75min and 135min annealing at 630 ${}^{\mathcal{C}}$ respectively. The grain sizes in equivalent sphere diameter are given in the table.





Figure: Schematic illustration of the setup for diffraction contrast tomography data acquisition of the Al-5wt%Cu sample. Key acquisition parameters are marked. In this case, projection geometry is used with geometrical magnification factor of 16.4.





Figure: (Left) Example absorption contrast projection at a certain rotation angle. The Cu-rich phase, which mainly segregates at grain boundaries, appears brighter given a higher attenuation coefficient. (Right) Example diffraction contrast projection at a certain rotation angle.

Data Acquisition Parameters

System: ZEISS Xradia 520 Versa with LabDCT Pro

Absorption Contrast Tomography

- Data acquisition: vertical stitching (5 layers)
- Voltage: 80 kV
- Power: 7 W
- Objective: 4× Detector
- Source Sample distance: 13 mm
- Sample Detector distance: 35 mm
- Exposure: 1s / binning 2
- Number of projections: 1601
- Voxel size: 1.84 μm

Diffraction Contrast Tomography

- Data acquisition mode: Helical Phyllotaxis
- Aperture: DCT 250 \times 750 (μ m \times μ m)
- Voltage: 110 kV
- Power: 10 W
- Objective: Flat Panel Detector
- Source Sample distance: 16 mm
- Sample Detector distance: 246 mm
- Exposure: 10s / binning 2
- Number of projections: 2900
- 3D Grain Map voxel size: 6 μm



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